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Room # 307

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q67844

Takako SUZUKI, et al.

Appln. No.: 10/084,204

Group Art Unit: 1752

Confirmation No.: 6177

Examiner: John S. Y. Chu

Filed: February 28, 2002

For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING
RESIST PATTERN USING SAME

REQUEST FOR REFUND

MAIL STOP 16

Director of the U.S. Patent and Trademark Office

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Applicant hereby respectfully requests a refund in the amount of \$2920.00. This refund is to be credited to Deposit Account No. 19-4880.

Check No. 231697 was submitted on September 29, 2003, in the amount of \$930.00 (Petition for Extension of Time for three (3) months) and Check No. 231698 was submitted on September 29, 2003, in the amount of \$110.00 (Submission of Terminal Disclaimer) for fees in connection with this application. However, Deposit Account No. 19-4880 was charged for the following fees:

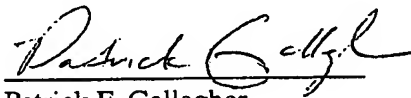
Date	Fee Code	Charges/Credits
March 4, 2004	1253	\$950.00
March 4, 2004	1253	\$930.00
March 5, 2004	1253	\$930.00
March 5, 2004	1814	\$110.00

REQUEST FOR REFUND
U.S. Application No. 10/084,204

Q67844

Due to the duplicate charges, SUGHRUE MION, PLLC requests that a refund of \$1,252.00 be credited to Deposit Account No. 19-4480. Copies of the Deposit Account Monthly Statement showing the charges to our account, and copies of canceled check nos. 231637 and 231638 are attached herewith. A duplicate copy of this paper is attached.

Respectfully submitted,



Patrick F. Gallagher
Registration No. 54,109

SUGHRUE MION, PLLC
Telephone: (202) 293-7060
Facsimile: (202) 293-7860

WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: January 21, 2005

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Docket No: Q67844
 Takako SUZUKI, et al.
 Appln. No.: 10/084,204 Group Art Unit: 1752
 Confirmation No.: 6177 Examiner: Unknown
 Filed: February 28, 2002

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For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING RESIST
 PATTERN USING SAME

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents
 P.O. Box 1450
 Alexandria, VA 22313-1450

FILED
 SEP 8 8 2003

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of three month(s), extending the time for responding to the Office Action of March 27, 2003 to September 29, 2003 (September 27, 2003 being a Saturday).

A check for the statutory fee of \$930.00 is attached. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

Lee C. Wright
 Lee C. Wright
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WASHINGTON OFFICE
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Date: September 29, 2003

PAGE 3/17 * RCVD AT 2/11/2004 5:07:44 PM [Eastern Standard Time] * SVR:USPTO-EFIDF-101 * DMS:1720008 * CSD:202-253-2020 * DURATION [mm:ss]:04:46

Adjustment Date: 03/15/2005 SDIRETA1
 03/05/2004 PFENNELL 00000004 194880 10084204
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 03/05/2004 PFENNELL 00000006 194880 10084204
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Adjustment Date: 03/15/2005 SDIRETA1
 03/04/2004 PFENNELL 00000003 194880 10084204
 01 FC:1253 950.00 CR

Adjustment date: 03/15/2005 SDIRETA1
 03/04/2004 PFENNELL 00000004 194880 10084204
 01 FC:1253 930.00 CR